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(12) **United States Design Patent**
Farrell

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(54) **HOSPITAL GOWN WITH V-NECK**

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(*) Notice: This patent is subject to a terminal disclaimer.

(**) Term: **14 Years**

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(51) **LOC (8) Cl.** **02-02**

(52) **U.S. Cl.** **D2/720**

(58) **Field of Classification Search** D2/717,
D2/720, 724, 728, 731, 737, 739, 756; 2/69,
2/74, 83, DIG. 4

See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

4,332,033	A *	6/1982	Frank	2/105
4,622,699	A *	11/1986	Spriggs	2/114
4,718,124	A *	1/1988	Sawicki et al.	2/114
4,964,173	A *	10/1990	Gordon et al.	2/114
5,184,351	A *	2/1993	Benstock	2/114

5,271,100	A *	12/1993	Holt	2/114
D378,157	S *	2/1997	Jagger	D2/720
D381,488	S *	7/1997	Small	D2/720
5,913,407	A *	6/1999	Keyes	2/83
5,991,923	A *	11/1999	Maria	2/83
D444,291	S *	7/2001	Poradzisz	D2/844
6,460,187	B1 *	10/2002	Siegel	2/114
2005/0262614	A1 *	12/2005	Eisenberg	2/114

* cited by examiner

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(57) **CLAIM**

The ornamental design for a hospital gown with V-neck, as shown and described.

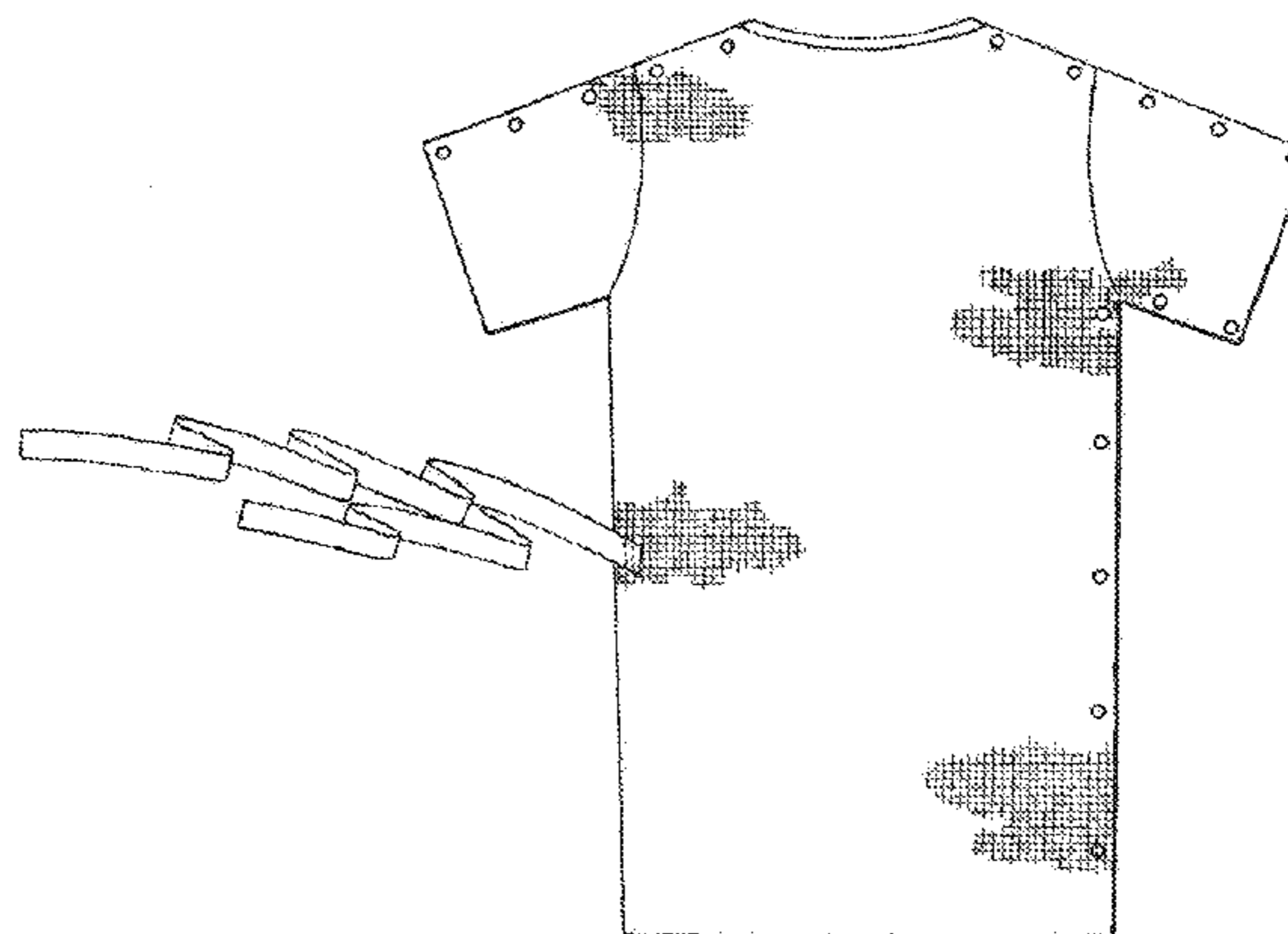
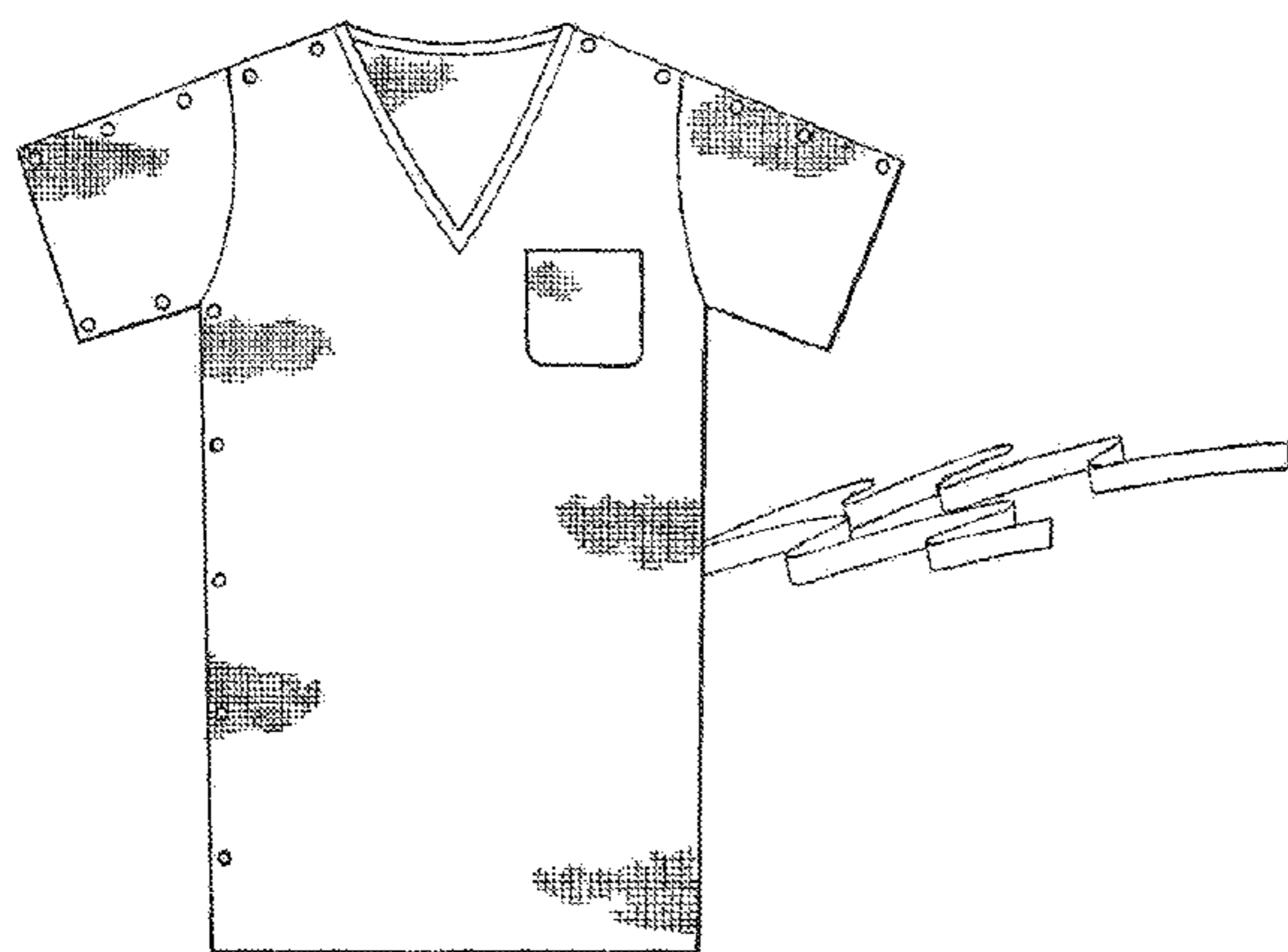
DESCRIPTION

FIG. 1 is a front elevational view of a hospital gown with V-neck showing my new design; and,

FIG. 2 is a rear elevational view thereof.

The broken lines shown on the tie straps in FIG. 2 represent stitching.

1 Claim, 1 Drawing Sheet



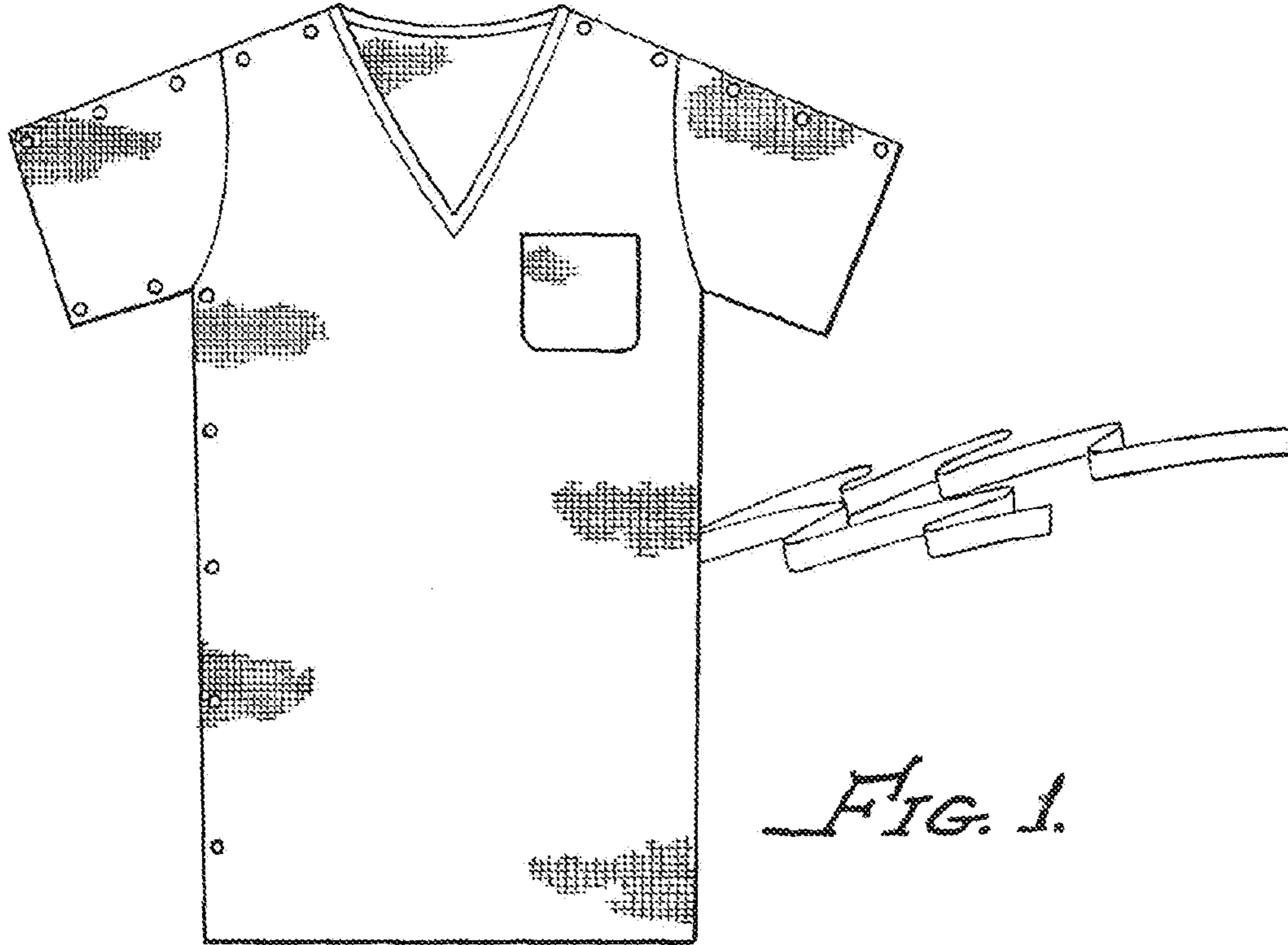


FIG. 1.

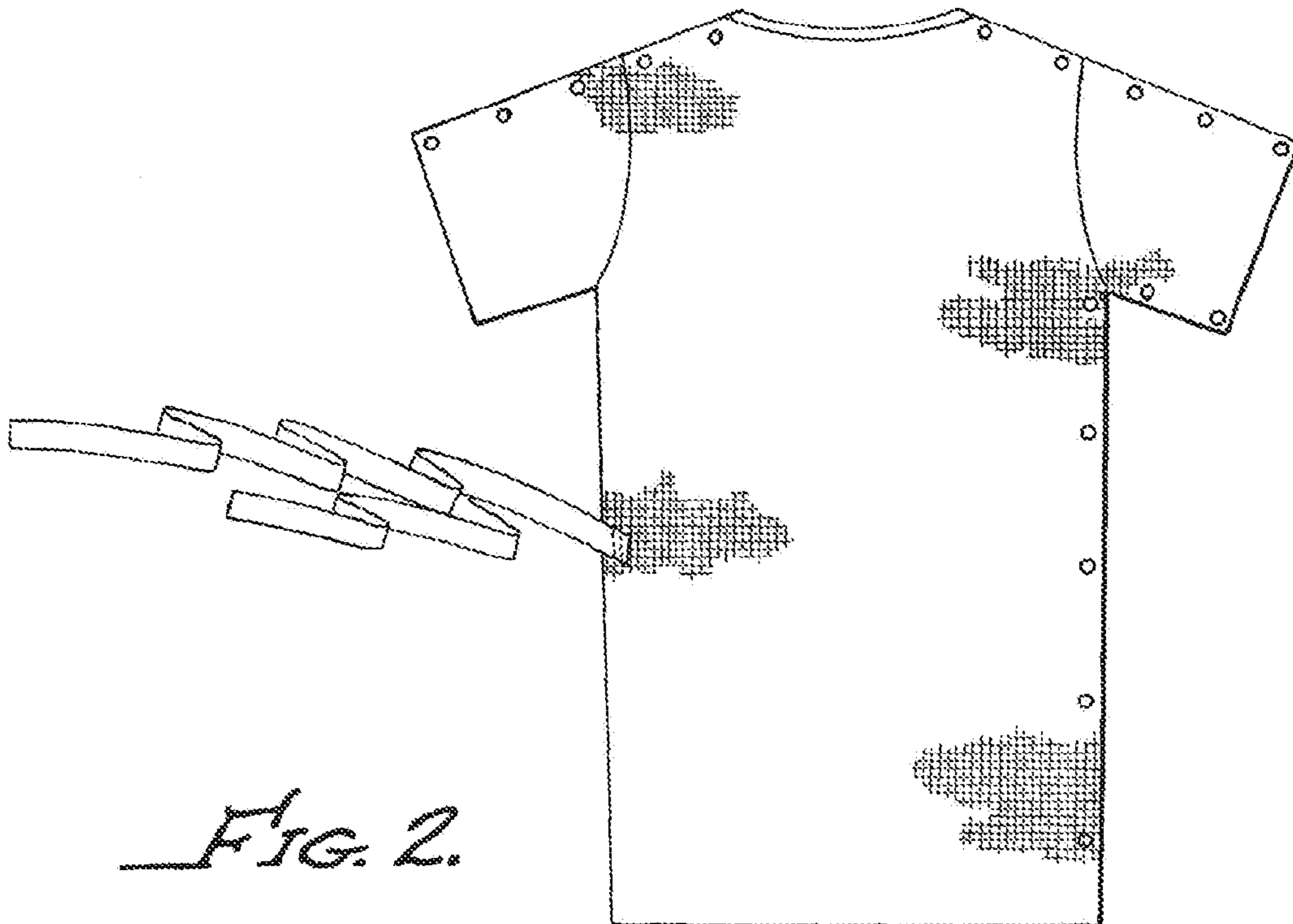


FIG. 2.